OIPE JC177
DEC 04 2003
PATENT & TRADEMARK OFFICE

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

Hisayoshi Ohba et al. Group Art Unit: 2825

Application No.: 10/032,498 Examiner: Lin, Sun J.

Filed: January 02, 2002 Atty. Docket No.: 108066-00047

For: LSI DESIGN METHOD HAVING DUMMY PATTERN GENERATION PROCESS AND LCR EXTRACTION PROCESS AND COMPUTER PROGRAM THEREFOR

AMENDMENT UNDER 37 C.F.R. § 1.121

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

December 4, 2003

Sir:

In reply to the Office Action mailed August 4, 2003, please amend the above-identified application as follows.

RECEIVED
DEC 11 2003
TECHNOLOGY CENTER 2800